

INEL-6080  
VLSI SYSTEMS DESIGN

Lecture 2

**Characteristics of  
Digital ICs**

## CHARACTERISTICS OF DIGITAL ICs

# Quality Metrics in IC Design

1. Cost
  - Resource investment to produce a batch of ICs
2. Functionality
  - IC ability to perform the function it was designed for
3. Performance
  - Circuit speed: delay, operating frequency, and processing capability
4. Robustness
  - Ability to withstand process variations and noise disturbances
5. Power and Energy Consumption
  - Energy consumed for IC operation and heat dissipation

## CHARACTERISTICS OF DIGITAL ICs

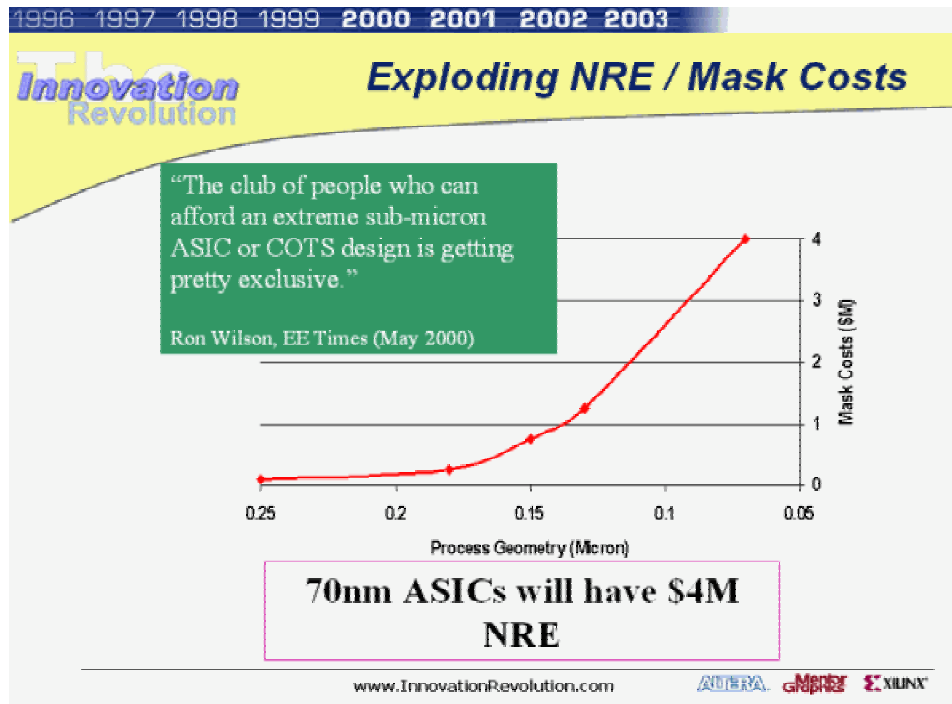
# Cost of an Integrated Circuit

- Non-recurrent Engineering (NRE) Costs (Fixed)  
*One-time cost factors. Independent from production volume*
  - Design time and effort
  - Mask generation
  - Indirect costs: R&D, infrastructure, marketing, etc.
- Recurrent Costs (Variable)  
*Cost directly attributable to a manufactured product. Proportional to chip area and product volume*
  - Silicon processing
  - Die testing
  - IC packaging

$$\text{Cost per IC} = \text{Recurrent Cost per IC} + \left( \frac{\text{NRE Cost}}{\text{Volume}} \right)$$

## CHARACTERISTICS OF DIGITAL ICs

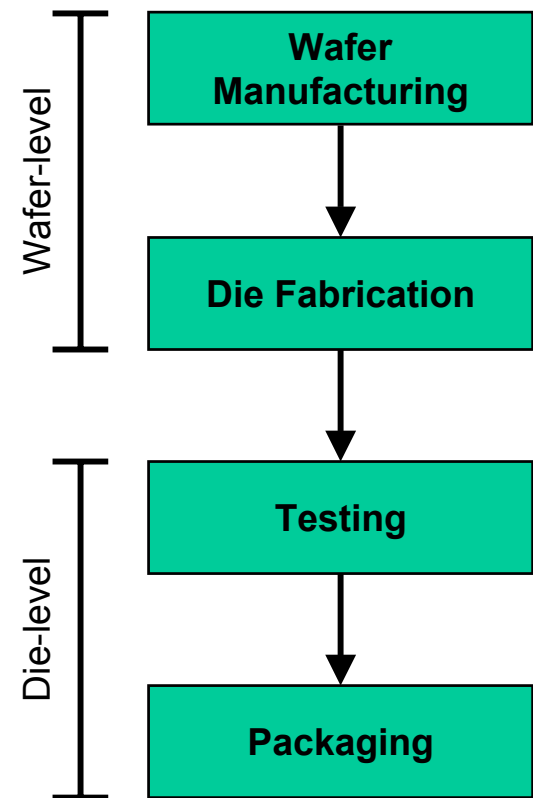
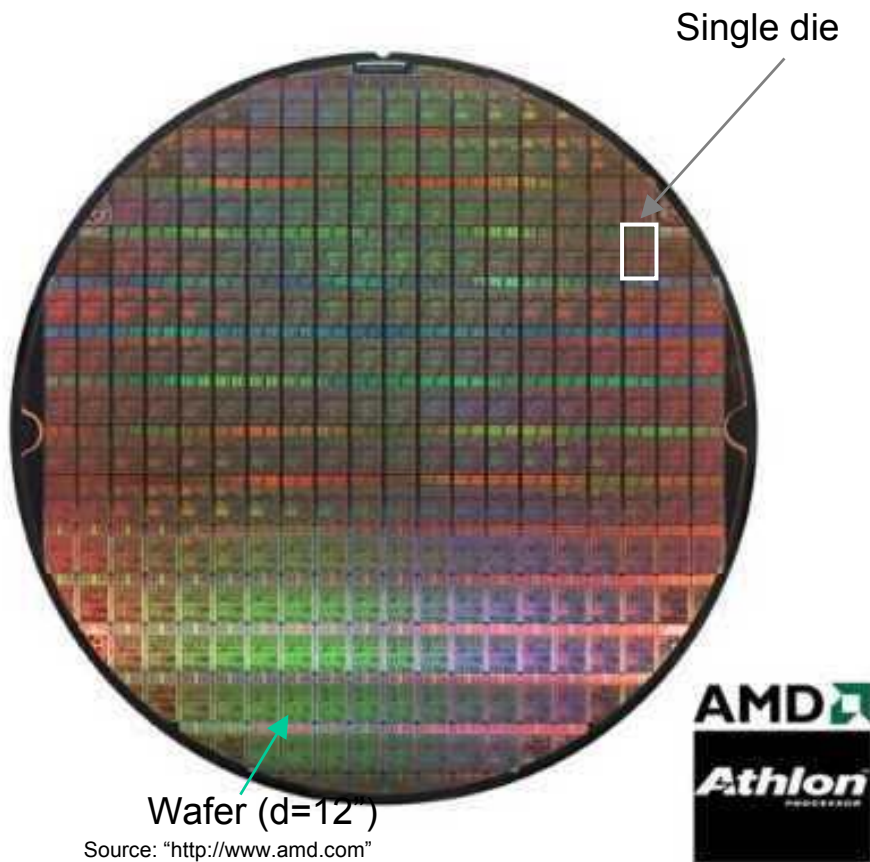
# Fixed Costs



- Increase with:
  - Technology scale-down
  - Stringent design specifications
  - Chip complexity
- Decrease with:
  - Design automation level

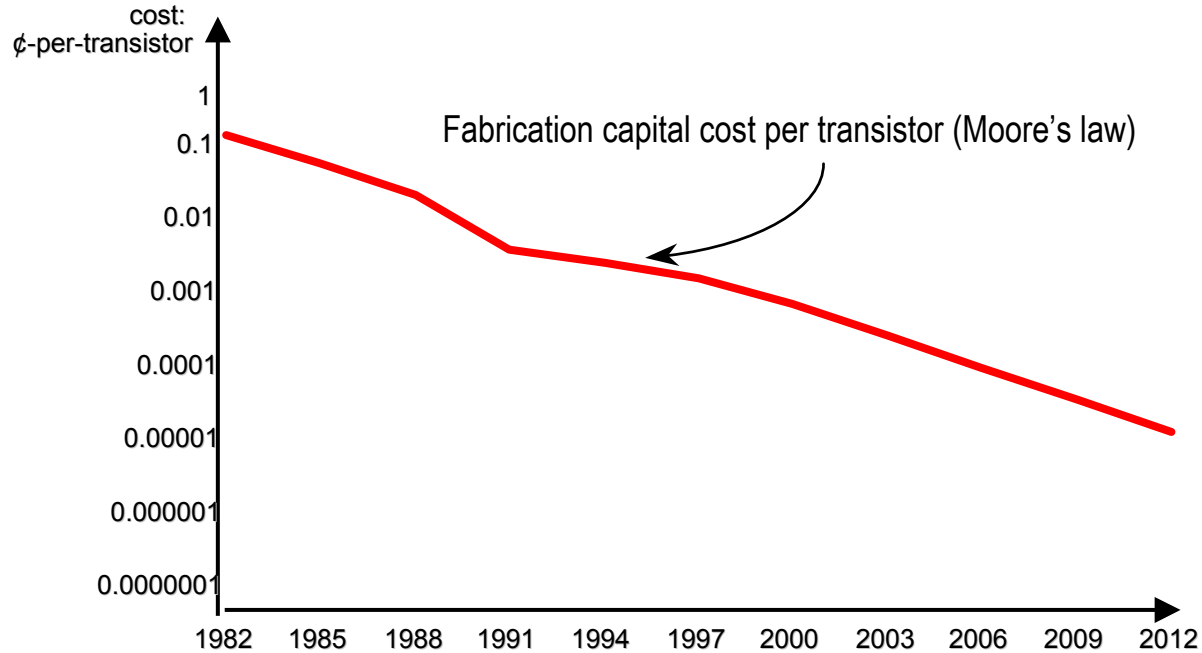
## CHARACTERISTICS OF DIGITAL ICs

# Variable Costs



## CHARACTERISTICS OF DIGITAL ICs

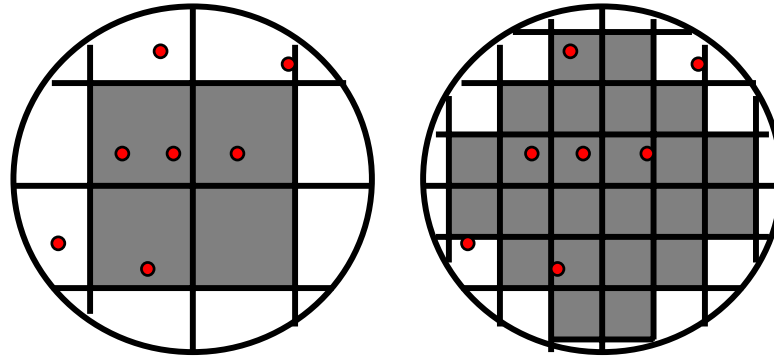
# Variable Cost Computation



$$\text{Variable cost} = \frac{\text{Die cost} + \text{Testing cost} + \text{Packaging cost}}{\text{Test yield}}$$

CHARACTERISTICS OF DIGITAL ICs

# Die Cost and Yield



$$\text{Dies per wafer} = \frac{\pi \times (\text{wafer diameter}/2)^2}{\text{die area}} = \frac{\pi \times \text{wafer diameter}}{\sqrt{2 \times \text{die area}}}$$

$$\text{Yield} = \frac{\text{No. of good chips per wafer}}{\text{Total number of dies per wafer}} \times 100\%$$

$$\text{Die cost} = \frac{\text{Wafer cost}}{\text{Dies per wafer} \times \text{Die yield}}$$

## CHARACTERISTICS OF DIGITAL ICs

# Estimating Variable Costs

- Cost estimation during design phase
  - Based on process characterization information and design information

$$\text{Die yield} = \left( 1 + \frac{\text{defects per unit area} \times \text{die area}}{\alpha} \right)^{-\alpha}$$

$\alpha$  is approximately 3

$$\text{die cost} = f(\text{die area})^4$$



CHARACTERISTICS OF DIGITAL ICs

# A Few Cost Examples

Based on production data back in 1994

Chip	Metal layers	Line width	Wafer cost	Def./cm <sup>2</sup>	Area mm <sup>2</sup>	Dies/wafer	Yield	Die cost
386DX	2	0.90	\$900	1.0	43	360	71%	\$4
486 DX2	3	0.80	\$1200	1.0	81	181	54%	\$12
Power PC 601	4	0.80	\$1700	1.3	121	115	28%	\$53
HP PA 7100	3	0.80	\$1300	1.0	196	66	27%	\$73
DEC Alpha	3	0.70	\$1500	1.2	234	53	19%	\$149
Super Sparc	3	0.70	\$1700	1.6	256	48	13%	\$272
Pentium	3	0.80	\$1500	1.5	296	40	9%	\$417

## CHARACTERISTICS OF DIGITAL ICs

# Performance

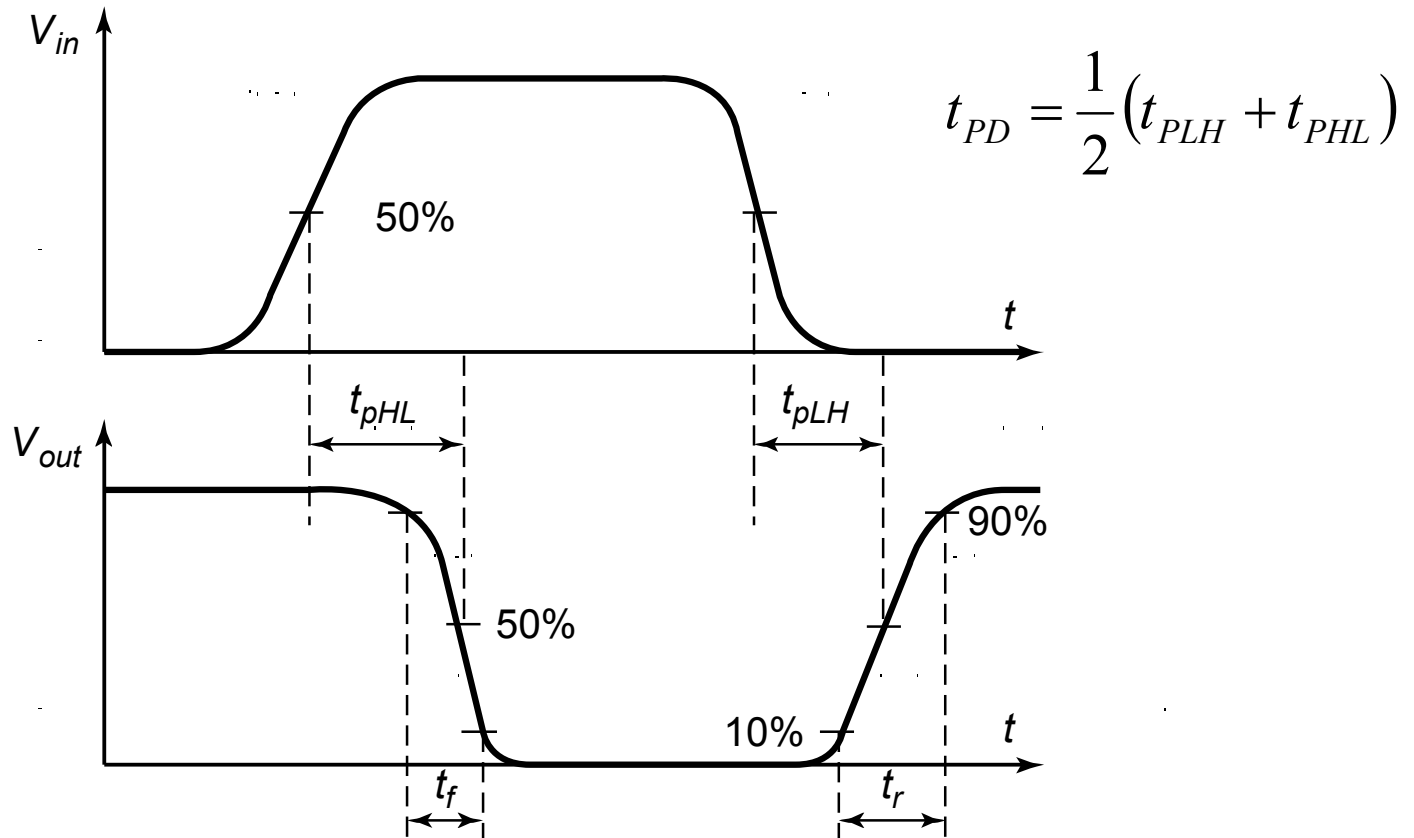
- Computational speed of a digital circuit:
  - Microprocessor: MIPS
  - Digital Gate: Propagation Delay

*Amount of time it takes an input stimulus to produce a change in the gate output*

- Parameters:
  - $t_{PHL}$  = Low-high propagation delay
  - $t_{PLH}$  = High-low propagation delay
  - $t_{PD}$  = Average propagation delay
  - $t_r$  = Rise time
  - $t_f$  = Fall time

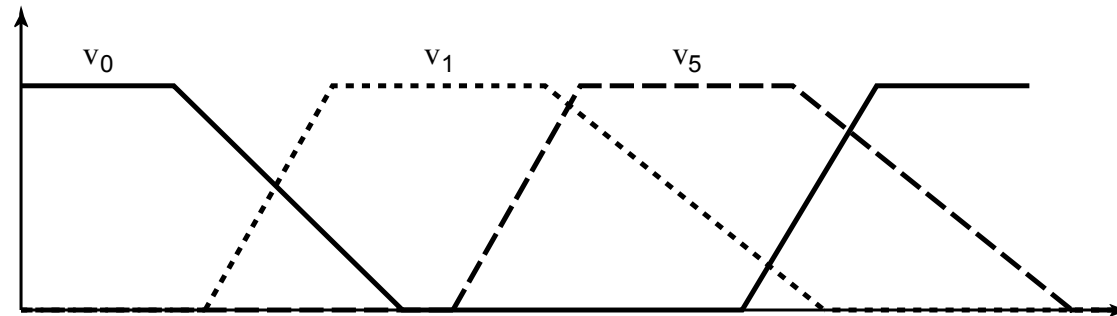
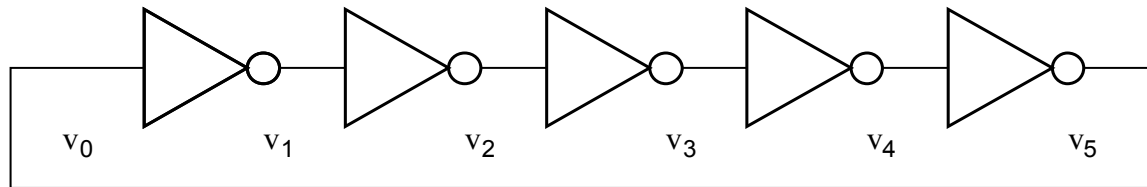
## CHARACTERISTICS OF DIGITAL ICs

# Delay Definitions



## CHARACTERISTICS OF DIGITAL ICs

# Ring Oscillator

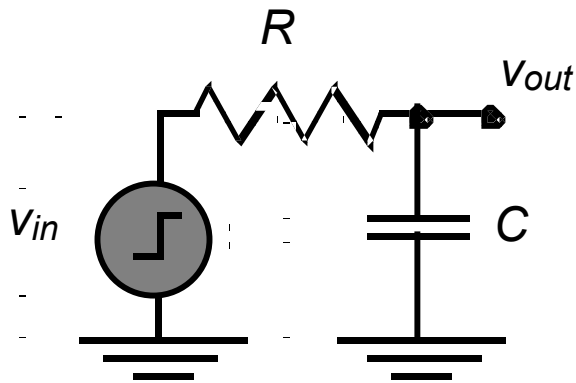


$$T = 2 \times t_{PD} \times N$$

$N$  odd

$$T \gg t_r + t_f$$

# A First-Order RC Network



$$v_{out}(t) = (1 - e^{-t/\tau}) V$$

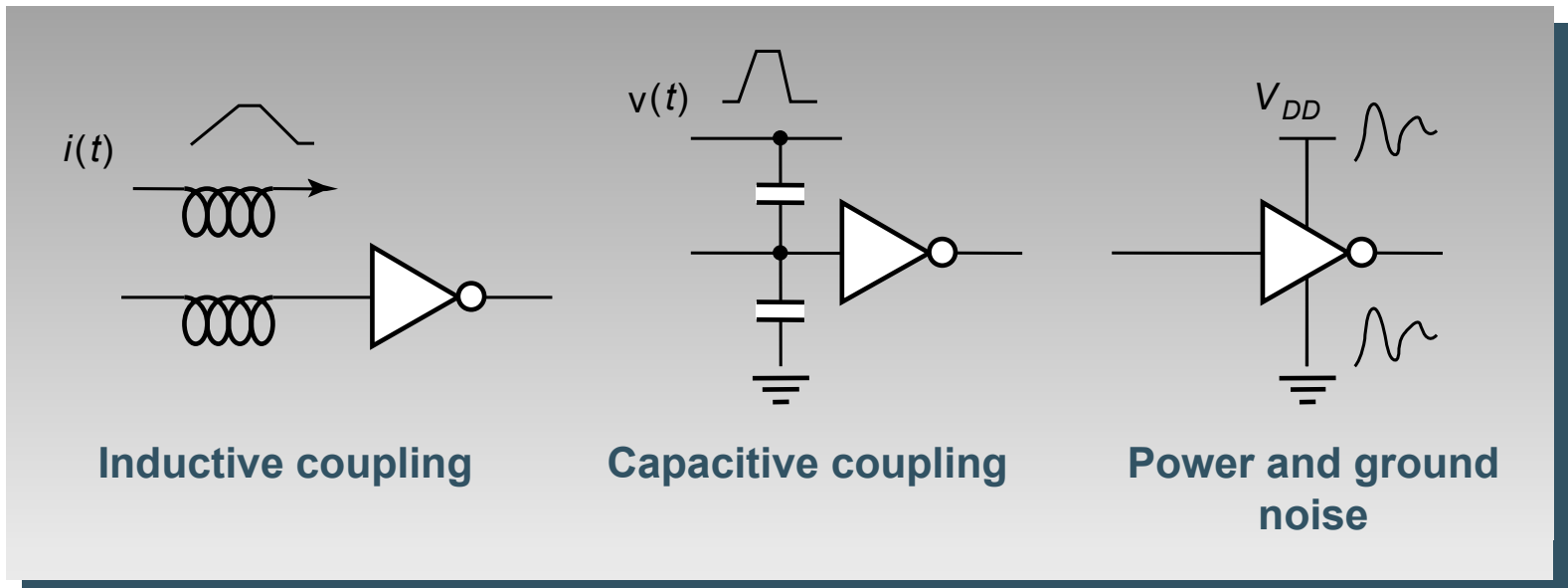
$$t_p = \ln(2) \tau = 0.69 RC$$

Important model - matches delay of inverter

# CHARACTERISTICS OF DIGITAL ICs

## Functionality and Robustness

- Sources of Noise in Digital ICs:
  - Crosstalk (Inductive and capacitive coupling)
  - Reflections and ringing
  - Power Supply Noise



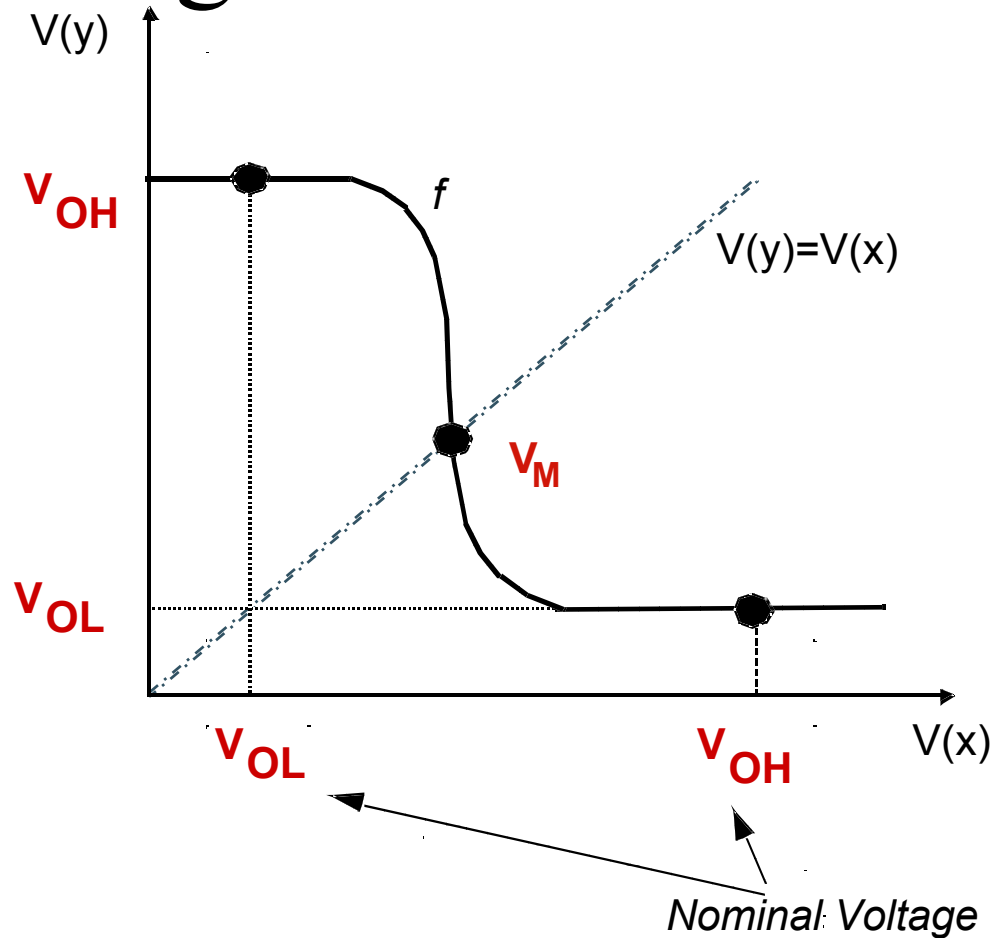
CHARACTERISTICS OF DIGITAL ICs

# Robustness Parameters

- Voltage Transfer Characteristic
- Noise Immunity
- Regenerative Property
- Directivity
- Fan-in and Fan-out

## CHARACTERISTICS OF DIGITAL ICs

# Voltage Transfer Characteristic



$$\text{VTC: } v_{out} = f(v_{in})$$

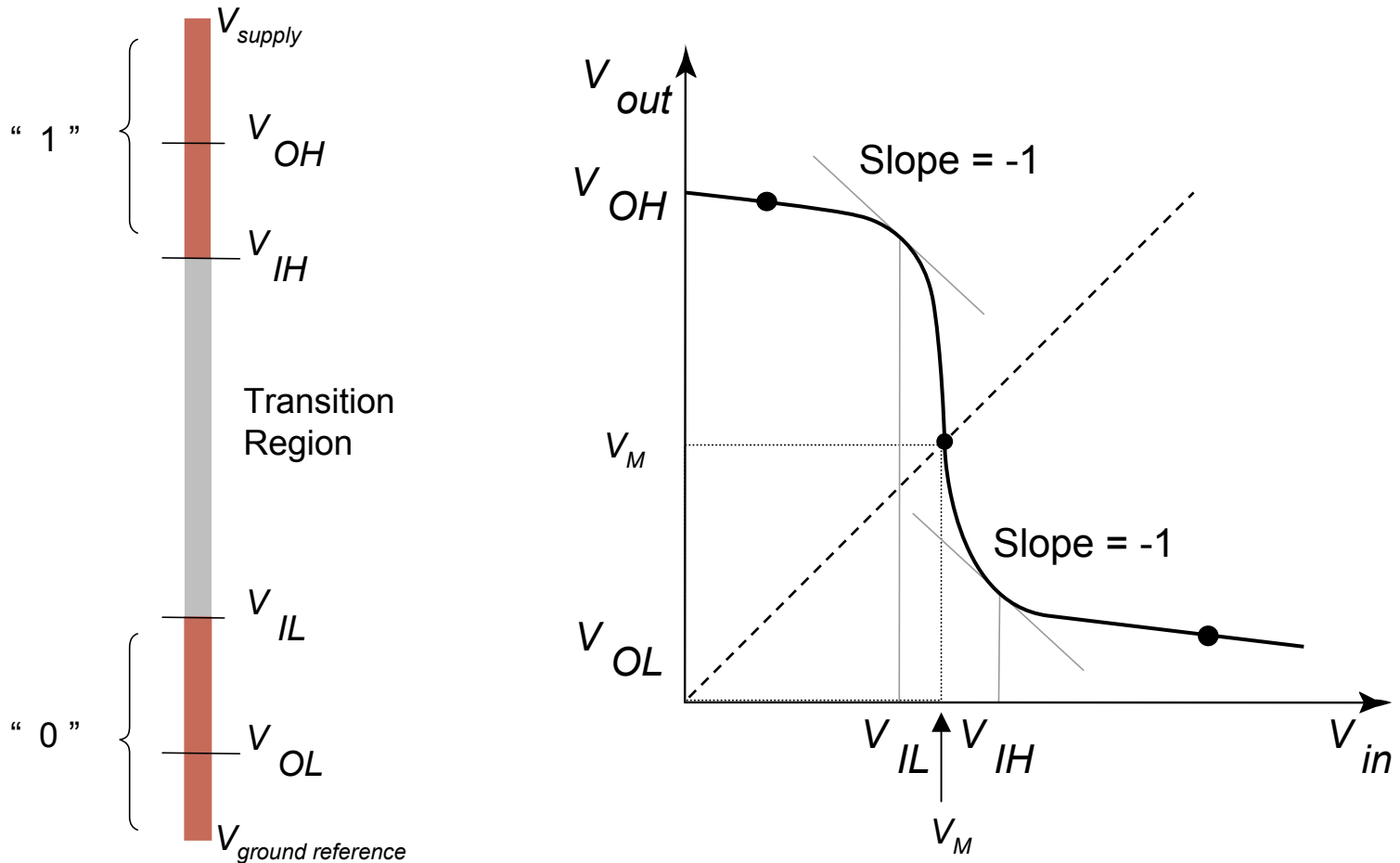
Inverting VTC

$$\begin{aligned} V_{OH} &= f(V_{OL}) \\ V_{OL} &= f(V_{OH}) \\ V_M &= f(V_M) \end{aligned}$$



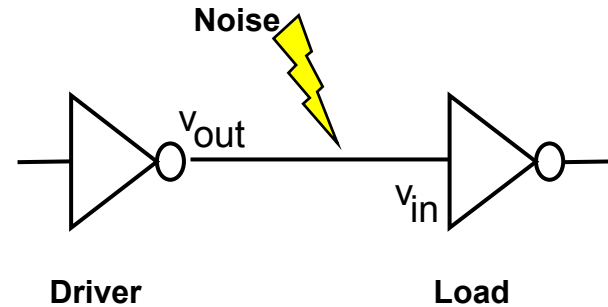
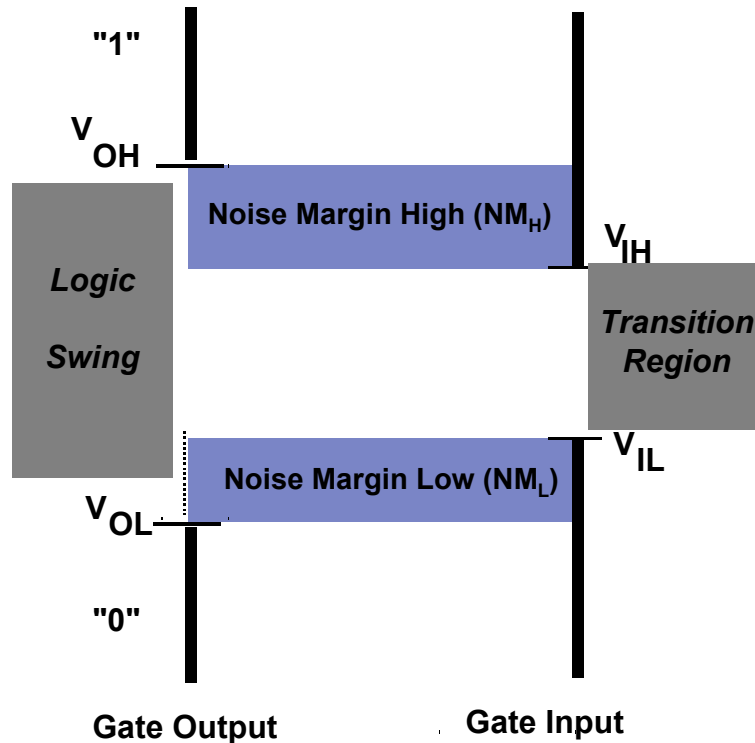
# CHARACTERISTICS OF DIGITAL ICs

## VTC Thresholds



## CHARACTERISTICS OF DIGITAL ICs

# Noise Margins



$$NM_L = V_{IL} - V_{OL}$$

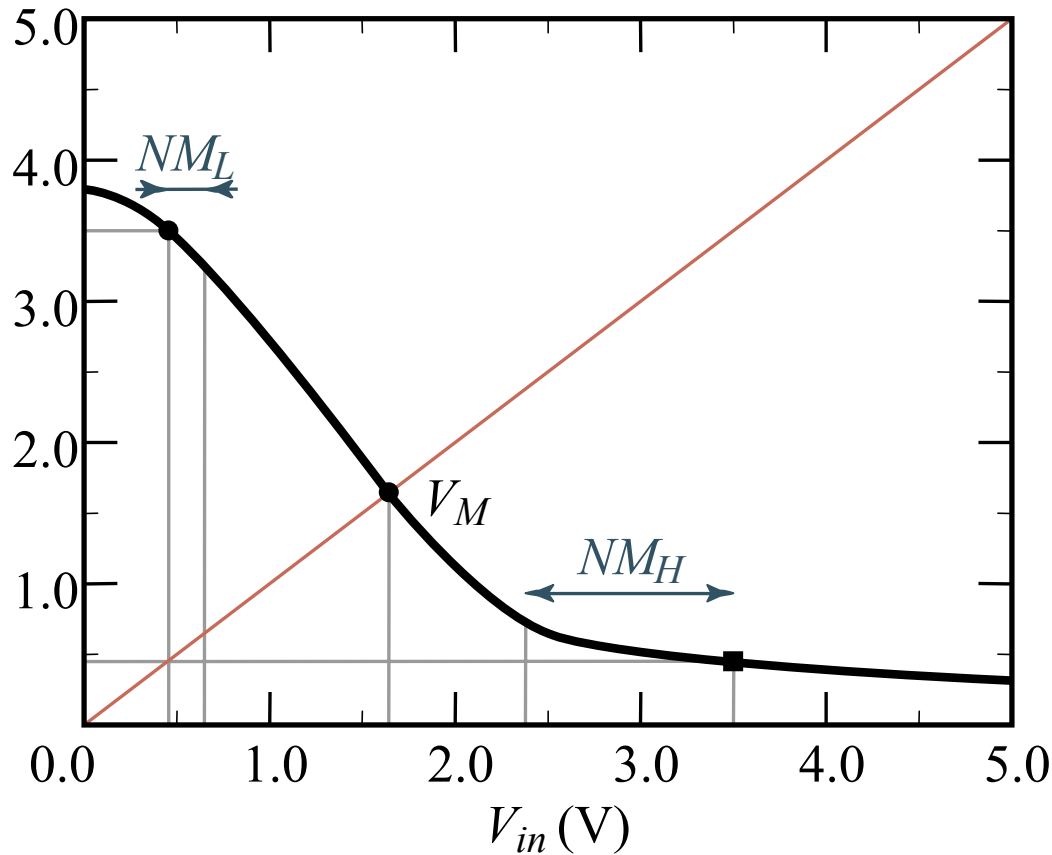
$$NM_H = V_{OH} - V_{IH}$$

$$\text{Logic Swing} = V_{OH} - V_{OL}$$

Transition Region : From  $V_{IL}$  to  $V_{IH}$

## CHARACTERISTICS OF DIGITAL ICs

# Example: Inverting VTC



$$V_{OH} = 3.5V$$

$$V_{OL} = 0.45V$$

$$V_M = 1.64V$$

$$V_{IH} = 2.35V$$

$$V_{IL} = 0.66V$$

$$MNL = 0.21V$$

$$NM_H = 1.15V$$

$$LS = 3.05V$$

Transition region

0.66V to 2.35V